We are IntechOpen, the world’s leading publisher of Open Access books
Built by scientists, for scientists

4,000 Open access books available
116,000 International authors and editors
120M Downloads

154 Countries delivered to
TOP 1% Our authors are among the
most cited scientists
12.2% Contributors from top 500 universities

WEB OF SCIENCE™
Selection of our books indexed in the Book Citation Index in Web of Science™ Core Collection (BKCI)

Interested in publishing with us?
Contact book.department@intechopen.com

Numbers displayed above are based on latest data collected.
For more information visit www.intechopen.com
Chapter 10

Trap Level Measurements in Wide Band Gap Materials by Thermoluminescence

Pooneh Saadatkia, Chris Varney and Farida Selim

Abstract

The electrical and optical properties of wide band gap materials are greatly affected by the presence of defects in the band gap. Identification and characterization of these defects that act as electron and hole traps are essential to understand charge carrier and exciton dynamics and ultimately control the electrical and optical properties of dielectrics and semiconductors. In this chapter, we will demonstrate how thermoluminescence (TL) spectroscopy can be used to characterize traps and measure their energy levels in the band gap. An advanced wavelength-based TL spectrometer will be presented, and its applications for the evaluation of trap levels and the characterization of donors and acceptors in semiconductors and dielectrics will be discussed.

Keywords: dielectrics and semiconductors, wide band gap materials, trap levels, exciton dynamics, luminescence

1. Introduction

The electrical and optical properties of materials are greatly affected by the presence of deep and shallow traps in the band gap. Deep traps capture charge carriers and prevent their recombination while shallow traps affect the transport of charge carriers and excitons in the lattice. Thus, identification and characterization of the electron and hole traps are essential to understand exciton and charge carrier dynamics and ultimately control the electrical and optical properties of dielectrics and semiconductors. Thermoluminescence (TL) spectroscopy can offer a powerful tool for the study of traps and the measurement of their depth in the band gap. It is commonly used for dosimetry and has also been applied for defect investigation and radiation damage studies. Recently, we have developed an advanced wavelength-based TL spectrometer for the evaluation of trap levels and the characterization of donors and acceptors and employed it to study a number of semiconductors and dielectrics.
This chapter explains in detail the basics of TL spectroscopy and introduces the reader to its use as an effective method for trap and donor and acceptor characterization. Then it describes the experimental details of an advanced TL spectrometer, explains how to construct TL glow curves, and discusses different approaches for the calculations of trap levels in the band gap. The chapter also discusses in brief some of the complimentary methods that can be used in parallel with TL for the full characterization of traps including their structure, type, density, and energy level. Examples of these methods include positron annihilation and optical absorption spectroscopies. A few TL studies of traps in semiconductors and dielectrics are presented.

The chapter is organized as follows. It begins in Section 2 with a historical background about TL and its applications to radiation dosimetry and defect studies then it discusses the TL process and physics in Section 3. Section 4 gives a complete analysis for activation energy and trap level calculations including initial rise method, different heating rate method for first-order kinetics, and finally, it describes an analysis of general order kinetics. In Section 5, we describe the standard TL setup “TL reader”, then introduce our advanced TL spectrometer that is especially useful for the study of traps in dielectrics and the characterization of donors and acceptors in semiconductors. Sections 6 and 7 discuss in detail the application of TL in the study of wide band gap materials by presenting our recent studies on yttrium aluminum garnet (YAG) as an example of dielectrics and ZnO as an example of wide band gap semiconductors.

2. Historical background

In Latin “lumen” means light, the term “luminescent” materials refer to materials that can emit light, especially in the visible range such as crystals, minerals, and chemical substances. Luminescence phenomena have been known for long times [1], it does not occur spontaneously, it needs some source of energy such as visible light, ultraviolet light, or X-rays in order to excite the sample [2]. Caspariolo [3] made the first attempt to create luminescence artificially from Bolognian stone in 1603. Afterwards, the stone and other luminescent materials were named “phosphor”. In 1852, Stokes [4] formulated luminescence law, the energy of emission is typically less than the energy of absorption; therefore, luminescence occurs at lower energies or longer wavelengths. Later in 1888, Weidemann [5] used the term “luminescenz” for all phenomena of light not produced through increased temperature, i.e., incandescence. Luminescence is classified to many types such as photoluminescence, cathodoluminescence, thermoluminescence, and X-ray luminescence [6, 7].

Measuring material properties as a function of temperature is called thermally stimulated processes (TSPs) that are usually as follows: first, the sample is perturbed, in most cases by exposure to some source of ionizing radiation, then by elevating the temperature, it is thermally stimulated back to equilibrium that releases accumulated energy as light emission in TL or as current in thermally stimulated conductivity [8]. We will limit our discussion and literature review in this chapter to TL spectroscopy. Existence of thermoluminescence in crystals is dependent on the presence of crystal defects that are capable of absorbing some part of incident energy during irradiation, and only emit light after heating the material [9–13].
Different types of irradiation sources can be used to excite the samples in TL measurement such as $\gamma$-rays, X-rays, and UV radiation. The dependence of energy absorbed during irradiation, which is termed “radiation dose” and defined as dose rate × time of exposure makes TL very effective in radiation dosimetric applications [14, 15] in medicine, industry, biology and agriculture, and also in dating of ancient pottery sherds and certain rocks [16, 17]. Besides dosimetric applications, thermoluminescence spectroscopy is a versatile tool for defect studies in crystals and trapping phenomena at the grain boundaries in nanostructures and soft materials.

The TL glow curve represents the intensity of emitted light versus temperature; each glow peak is associated with recombination center and related to specific trap. Activation energy and escape frequency factor can be calculated from the glow curve [18]. As mentioned in the introduction, TL is an important technique for investigating of nature and depth of traps in the different type of solids [19, 20], and various methods can be used to calculate trap parameters based on the kinetics order of glow peaks such as initial rise method and variable heating rates that will be discussed later. Heating rate has critical effect on the intensity and peak area of thermoluminescence glow peaks [21]. Variable heating rate techniques including very slow heating rate down to 0.0008°C/s were used to investigate the TL of CaSO$_4$: Tm phosphor. Using slow heating rates helped to resolve eight narrow components in the TL glow curve [22]. Because of inner shell electronic transitions, rare-earth ions and transition metal ions are considered excellent luminescence centers [23–28]. For example, TL measurement was applied to investigate the luminescence efficiency of rare-earth ions doped SrTiO$_3$:Pr$^{3+}$ [28]. The authors used a 100 W deuterium lamp for excitation and measured emission from as-fired SrTiO$_3$:Pr$^{3+}$ and annealed samples in reduced atmosphere (5% H$_2$ and 95% Ar). They observed a considerable decrease in the TL intensity of the annealed samples, which were attributed to the suppression of traps. They also tried to increase the luminescence efficiency of SrTiO$_3$:Pr$^{3+}$ by adding impurities. After adding Al, new peaks were appeared, it seems that above 150 k, Al$^{3+}$ ions are responsible for providing free carriers, which help to improve the luminescence efficiency of Pr$^{3+}$ [28].

Recently, nanosized phosphor has fascinated researchers, and its applications have been emerged in different fields of materials especially luminescence area [29]. They have great potential for high dose detection in dosimetry applications [30, 31]. ZrO$_2$ nanophosphor is a good example where TL spectroscopy was successfully applied to study its properties [30]. Different concentrations of titanium were used as dopants to study TL behavior of ZrO$_2$ nanophosphors [32]. Samples were exposed to 254 nm UV for variable times in order to study the effect of time exposure and dose on TL intensity. Trapping parameters, i.e., activation energy and frequency factor were also calculated with different heating rate and peak shape methods. By increasing the heating rate, peaks position were shifted to higher temperature side. The sample was found to be useful for TL dosimetry applications due to linear dose response, high stability, and low fading phenomenon. Two peaks were observed at 167 and 376°C with fixed positions, and enhancing or quenching of intensity was found to be strongly dependent on dopant concentrations. Similarly, Tamrakar et al. [33] used TL spectroscopy to study the effect of different concentration of Er$^{3+}$ as dopant for gadolinium oxide nanophosphor (Gd$_2$O$_3$:Er$^{3+}$ phosphor). They found shallow and deep traps when using...
254 nm UV irradiation and Co\textsuperscript{60} gamma irradiation, respectively. In addition, gamma-irradiated samples indicated low fading and higher stability in comparison with samples exposed to UV. However, UV-irradiated Mn-doped CaYAl\textsubscript{3}O\textsubscript{7} phosphor indicates higher intensity compared to the samples irradiated by Gamma and megavoltage beam, indicating that by exposing to lower energy radiations, large numbers of shallower traps were formed [34]. Gamma rays have also been applied to irradiate pure LiF crystals to investigate trap levels and their connections to color centers generated during ionization process. The authors reported the relation of four color centers to four resolved and six unresolved glow peaks, which shows that TL spectroscopy is quite useful [35].

It is important to mention that the physical and optical properties of individual nanosize phosphor materials are often not the same as those of their bulk counterparts [36–39]. For example, activation energy and trap parameters were calculated by Tamrakar et al. [37, 40] from TL glow curve of bulk CdS and CdS: Cu phosphor nanoparticles using Chen’s peak shape methods [8, 41–43]. The former was found to exhibit first-order kinetics while the second one showed general order kinetics in TL emission implying the presence of charge retrapping in the nanoparticles. They also found that the level of excitation, presence of other traps, and preionized luminescence centers can affect the shape, intensity, and position of a glow curve.

3. Basics of TL process

In a typical TL measurement, a sample is irradiated with high-energy light for a duration, which excites electrons from the valence band or from the dopant levels within the band gap to the conduction band. The excited state is not stable, so after some time the charge carriers recombine. A fraction of charge carriers may be trapped at a defect or impurity and cannot recombine with their counterpart. After removal of the excitation, heating injects thermal energy into the system, providing the trapped charge carriers with the energy necessary to escape their traps. These released charge carriers can either recombine with their charge carrier counterpart at luminescence centers, giving rise to TL emission, or they can become trapped at a deeper, higher-energy trap. They possess too much energy at this point to retrap at the same type of trap they just escaped or any shallower trap. The probability of detrapping increases with raising temperature. Figure 1 presents a schematic diagram of the process of thermal stimulation and recombination of trapped charge carriers. TL emission intrinsically occurs at one or few luminescence centers. Thus, TL measurements provide a reliable method by which to record small luminescence intensities. This makes TL an ideal method for the characterization of trap levels in insulating crystals such as yttrium aluminum garnet (Y\textsubscript{3}Al\textsubscript{5}O\textsubscript{12}) [44–58].

4. Activation energy and trap level calculations

A plot of thermoluminescence intensity versus temperature is known as a glow curve. Analysis of glow curves can provide quantitative information about trap levels. Most notably, one may use glow curve analysis to calculate the depth of the charge carrier traps. The calculated
depth of a trap is referred to as its activation energy. To explain TL phenomena, Randall and Wilkins presented a model based on a single defect level within the band gap and assumed negligible retrapping, in which case the charge carrier can go straight to a luminescence center \([59-61]\). This is based on first-order kinetics of TL. Higher order kinetics assumes higher degrees of retrapping.

There are several methods to calculate activation energy from glow curves based on TL kinetics. The initial rise method calculates the activation energy directly by fitting the beginning of TL peak and is applicable to any order kinetics but can only be applied for nonoverlapping glow curves, where the peak being studied initially rises from the baseline \([2, 41, 55, 62-64]\). Other methods of activation energy calculation rely on conducting the experiment multiple times with different heating rates. At a faster heating rate, a glow curve shifts to higher temperature \([2, 41, 65]\). This effect is shown in Figure 2 for glow curves of YAG doped with Ce to 0.2% concentration (Ce:YAG 0.2%) at heating rates of 5, 10, 20, 30, 40, 50 and 60°C/min. The method of two heating rates uses two separate constant heating rates to cancel unknown terms in kinetics calculations, thus rendering activation energy calculation trivial \([2, 41, 55, 65-66]\). This method is limited by peak fitting capabilities, and since peak temperature is usually not very sensitive to the heating rate, can give large uncertainty.

This method is typically applied to first-order kinetics, but it is possible to apply this method to any order kinetics. Following the same principles as the method of two heating rates is the variable heating rate method, where several glow curves using different heating rates are constructed \([2, 55]\). As with the method of two heating rates, unknown terms cancel in kinetics.
equations, and in this case the activation energy can be determined graphically. The benefit of this method over the method of two heating rates is that the greater number of data points decreases uncertainty. This method is typically applied to first-order kinetics, but it can be generalized to any order kinetics. Other methods, such as the half-width method or direct computational glow curve fitting with the activation energy as a fitting parameter, are not explored in this chapter.

4.1. Initial rise method

Let us now derive each of the discussed methods for determining activation energies. The probability $p$ of an electron escaping from a trap of depth at temperature $T$ can be described by the Arrhenius Equations [60, 65, 67].

$$ p = s \exp \left( -\frac{E}{k_B T} \right) $$  \hspace{1cm} (1)

where $k_B$ is the Boltzmann constant and $s$, known as the frequency factor, is given by [67]
\[ s = N_B \nu \sigma_t \]  

(2)

where \( N_B \) is the density of states in the band in which the carriers escape, \( \nu \) is the carrier's thermal velocity, and \( \sigma_t \) is the trap's capture cross section. The frequency factor \( s \) has units of \( \text{time}^{-1} \) and may vary weakly with temperature. The rate of detrapping \( -\frac{dn}{dt} \) at temperature \( T \) can be expressed as

\[
-\frac{dn}{dt} = s n \exp \left( -\frac{E}{k_B T} \right)
\]

(3)

where \( n \) is the concentration of trapped charge carriers. Determining \( n(T) \) follows from Eq. (3) by

\[
\frac{dn}{dt} = -s n \exp \left( -\frac{E}{k_B T} \right) dt = -\frac{s}{q} \exp \left( -\frac{E}{k_B T} \right) dT
\]

(4)

where \( q = dT/dt \) is the heating rate, which for simplicity we shall assume is linear. Integration gives

\[
\ln \left( \frac{n}{n_0} \right) = -\int_{T_i}^{T} \frac{s}{q} \exp \left( -\frac{E}{k_B T'} \right) dT' + \text{constant}
\]

(5)

The prime in \( T' \) is introduced to distinguish between the variable and the upper limit of integration. When \( t = 0 \), let \( n = n_0 \) and \( T = T_i \) = some initial temperature, then the constant is equal to \( n_0 \) and we have

\[
\ln \left( \frac{n}{n_0} \right) = -\int_{T_i}^{T} \frac{s}{q} \exp \left( -\frac{E}{k_B T'} \right) dT'
\]

or

\[
n = n_0 \exp \left[ -\int_{T_i}^{T} \frac{s}{q} \exp \left( -\frac{E}{k_B T'} \right) dT' \right]
\]

(6)

The thermoluminescence intensity \( I \) is proportional to the rate that charge carriers are supplied to luminescence centers [2, 41, 60, 64–65, 68–69]:

\[
I(T) = c s n \exp \left( -\frac{E}{k_B T} \right)
\]

(7)

Combining this with Eq. (6),

\[
I(T) = c s n_0 \exp \left( -\frac{E}{k_B T} \right) \exp \left[ -\int_{T_i}^{T} \frac{s}{q} \exp \left( -\frac{E}{k_B T'} \right) dT' \right]
\]

(8)

which is known as the Randall-Wilkins first-order expression of a single glow peak [60]. For low temperatures (\( T = T_i \)), we may estimate \( n = n_0 \) and thus write
\[ I = cs n_0 \exp \left( \frac{-E}{k_B T} \right) \]  

The initial rise method, introduced by Garlick and Gibson [64], is based on Eq. (9). To calculate the activation energy by the initial rise method, we may rewrite Eq. (9) in a more useful form

\[ \ln(I) = \ln(cs n_0) - \frac{E}{k_B T} \]  

Plotting \( \ln(I) \) versus \( 1/k_B T \) gives the slope = \( E \).

The initial rise method is applicable to first, second, and even general order cases, but it is limited to the region where \( I_i \leq I < I_m \).

Bräunlich [62] showed that the values found for \( E \) using the initial rise method will be smaller than the actual values when the retrapping factor \( R[h(T_i)/f(T_i)] \) \( >> 1 \), where \( R \) is given by

\[ R = \frac{\text{probability of retrapping}}{\text{probability of recombination}} \]  

and \( h(T_i) \) and \( f(T_i) \) are traps with electrons and the initial concentration of unoccupied recombination centers, respectively (at the temperature \( T_i \)). This suggests that the initial rise method actually gives a poor estimate for \( E \) for high order kinetics.

Christodoulides [63] estimated a correction to the initial rise method that may be used if the intensity of the range used for calculation is larger than a small fraction of the peak height. The activation energy calculated by the initial rise method \( E_{IR} \) can be adjusted to the corrected value of the activation energy \( E_C \) by

\[ E_C = (1 + 0.74a_1 + 0.082a_2)E_{IR} - (2a_1 + 0.22a_2) \frac{T_m}{11,605} \]  

The factors \( a_1 \) and \( a_2 \) are the fraction of the peak value of the TL intensity observed at temperatures \( T_1 \) and \( T_2 \), respectively, marked as the lower and upper bounds of the fit, as demonstrated in Figure 3.

### 4.2. Methods of variable heating rates

The initial rise method is applicable to general order kinetics, but with decreased accuracy for higher order kinetics. However, if peaks are overlapped it is not possible to apply this method since the beginning of a peak is not available for analysis. The methods of two and variable heating rates only require that the peak temperature can be determined for calculation of \( E \).

These methods can be used with general order kinetics. The methods of two and variable heating rates can be derived from first-order kinetics or simplified from general order kinetics. We will first derive the method for general order kinetics and then apply it to the case of
first-order kinetics. It will be necessary to assume that $s$ is independent of temperature to proceed with this derivation. To general order of kinetics, Eq. (7) becomes \[ 1 \langle T \rangle = c s n^b \exp \left( - \frac{E}{k_B T} \right) \] (13)

where $s'$ is the general order preexponential factor, $b$ represents the order of kinetics, and $s' = s$ for $b = 1$. Eq. (13) can be integrated

\[ \int_{n_0}^{n} n'^b = -s' \int \exp \left( - \frac{E}{k_B T} \right) dt \] (14)

This has the solution...
\[ n^{1-b} = n_0^{1-b} \left[ 1 + \frac{s'(b-1)n_0^{b-1}}{q} \int T \exp \left( -\frac{E}{k_B T} \right) dT \right] \]

or

\[ n = n_0 \left[ 1 + \frac{s'(b-1)n_0^{b-1}}{q} \int \exp \left( -\frac{E}{k_B T} \right) dT \right] \]

The intensity of Eq. (13) then becomes

\[ I(T) = c s' \exp \left( -\frac{E}{k_B T} \right) n_0^{b-1} \left[ 1 + \frac{s'(b-1)n_0^{b-1}}{q} \int \exp \left( -\frac{E}{k_B T} \right) dT \right] \]

(15)

The maximum intensity of a peak occurs at temperature \( T_m \). At this point, the derivative of the intensity is zero, as is the derivative of the logarithm of the intensity. Thus, we obtain at \( T = T_m \) the relationship

\[ \frac{d[\ln(I(T))]}{dT} \bigg|_{T=T_m} = 0 = \frac{E}{k_B T_m^2} \frac{b}{b-1} \left[ 1 + \frac{s'(b-1)n_0^{b-1}}{q} \int \exp \left( -\frac{E}{k_B T} \right) dT \right]^{-1} \]

\[ \times \left( \frac{s'(b-1)n_0^{b-1}}{q} \exp \left( -\frac{E}{k_B T_m} \right) \right) \]

(17)

This yields

\[ 1 + \frac{s'(b-1)n_0^{b-1} T_m}{q} \int \exp \left( -\frac{E}{k_B T} \right) dT = \frac{b s' n_0^{b-1} k_B T_m^2}{q E} \exp \left( -\frac{E}{k_B T_m} \right) \]

(18)

The following approximation can be made

\[ \int T \exp \left( -\frac{E}{k_B T} \right) dT = k_B T_m^2 \sum_{n=1}^{\infty} \left( \frac{k_B T_m}{E} \right)^n (-1)^{-n} n! \]

(19)

which Kitidis and Pagonis determined is usually “a very good numerical approximation” [69].

The series converges quickly, so only the first two terms need to be taken. Inserting Eq. (19) into (18) yields

\[ 1 + \frac{s'(b-1)n_0^{b-1}}{q} \left[ T \exp \left( -\frac{E}{k_B T_m} \right) \left( \frac{2k_B T_m^2}{E^2} \right) \right] = \frac{b s' n_0^{b-1} T_m^2}{q E} \exp \left( -\frac{E}{k_B T_m} \right), \]

which becomes

\[ \frac{q E}{k_B T_m^2} = s' s_0^{b-1} \exp \left( -\frac{E}{k_B T_m} \right) \left[ 1 + (b-1) \frac{2k_B T_m}{E} \right] \]

(20)

At this point, we can calculate the first-order solutions for the method of two heating rates and the variable heating rate method by setting \( b = 1 \) and \( s' = s \).
Conducting a pair of TL measurements and recording the maximum temperature of a peak in both glow curves gives two such equations with different \( q \) and \( T_m \), but with the same \( E \) and \( s \). Division of one equation by the other gives

\[
\frac{q_1 T^2_{m2}}{q_2 T^2_{m1}} = \exp\left(\frac{E}{k_BT_m}\right)
\]

which can be solved for \( E \)

\[
E = k_BT_m \ln\left(\frac{q_1 T^2_{m2}}{q_2 T^2_{m1}}\right)
\]

which represents the activation energy to first-order kinetics using the method of two heating rates [2, 41, 65–66, 70]. The frequency factor can also be found by Eq. (21) once we have obtained \( E \).

The variable heating rate method adapts the method of two heating rates to the case of many heating rates, to be solved graphically. From Eq. (12), for first-order kinetics

\[
\ln\left(\frac{T^2_m}{q}\right) = E\left(\frac{1}{k_BT_m}\right) - \ln\left(\frac{s k_B}{E}\right)
\]

Data can easily be plotted in this way to give the activation energy as its slope. Figure 4 plots the data obtained from Figure 2 for calculation of \( E \) and \( s \) using Eq. (24). Once \( E \) is calculated, \( s \) may be calculated from the y-intercept.

Activation energies calculated using the initial rise method, corrected initial rise method [63], and the method of variable heating rates is compared and presented in Table 1.

Note that the activation energies found for Peaks 2 and 3 match closely between the method of multiple heating rates and the corrected initial rise method and that the initial rise method in those peaks gives a significantly smaller result than the method of two heating rates. The latter point suggests that we may see the effects of re-trapping proposed by Braunlich [62].

### 4.3. General order method of variable heating rates

The general order variable heating rate method and the method of multiple heating rates are as of yet poorly documented in the literature [2]. The solution of the general order variable heating rate method begins by taking the logarithm of Eq. (20)

\[
\frac{E}{k_BT_m} = \ln\left(\frac{s^{b-1} k_B T^2_m}{q E}\right) \left[1 + (b-1) \frac{2k_BT_m}{E}\right]
\]

which can be separated into the parts...
Figure 4. Data and fits for all three peaks using multiple heating rates to get the results.

<table>
<thead>
<tr>
<th>Peak 1 (470–720 nm, ~400 K)</th>
<th>Activation energy (eV)</th>
</tr>
</thead>
<tbody>
<tr>
<td>Method of multiple heating rates</td>
<td>1.16 ± 0.01</td>
</tr>
<tr>
<td>Initial rise method</td>
<td>0.88 ± 0.06</td>
</tr>
<tr>
<td>Corrected initial rise</td>
<td>1.46 ± 0.05</td>
</tr>
<tr>
<td>Peak 2 (470–720 nm, ~550 K)</td>
<td></td>
</tr>
<tr>
<td>Method of multiple heating rates</td>
<td>1.80 ± 0.05</td>
</tr>
<tr>
<td>Initial rise method</td>
<td>1.15 ± 0.06</td>
</tr>
<tr>
<td>Corrected initial rise</td>
<td>1.83 ± 0.10</td>
</tr>
<tr>
<td>Peak 3 (470–720 nm, ~600 K)</td>
<td></td>
</tr>
<tr>
<td>Method of multiple heating rates</td>
<td>2.08 ± 0.05</td>
</tr>
<tr>
<td>Initial rise method</td>
<td>1.49 ± 0.07</td>
</tr>
<tr>
<td>Corrected initial rise</td>
<td>1.97 ± 0.05</td>
</tr>
</tbody>
</table>

Table 1. Calculated activation energies for the three major peaks found in Ce:YAG 0.2% thermoluminescence measurements from room temperature to 400°C using all methods previously discussed.
\[
\frac{E}{k_B T_m} = \ln \left( \frac{T_m^2}{q} \right) + \ln \left[ 1 + \frac{2k_B T_m}{E} \left( b - 1 \right) \frac{C_1}{C_2} + \left( \frac{C_1}{C_2} \right)^2 \right] + \ln \left( \frac{s' n_0^{b-1} k_B}{E} \right) 
\]  
(26)

The activation energy is typically at least an order of magnitude larger than \(k_B T_m\) [2], so we can apply the series expansion for \(\ln(1 + x)\) for \(x \leq 1\) to get

\[
\ln \left( \frac{T_m^2}{q} \right) = \ln \left( \frac{E}{s' n_0^{b-1} k_B} \right) + \frac{E}{k_B T_m} - 2(b-1) \frac{k_B T_m}{E} \left( b - 1 \right) \frac{C_1}{C_2} - 2 \frac{(b-1)^3 k_B^3 T_m^3}{3 E^2} + \ldots 
\]  
(27)

If we let \(y = \ln(T_m^2/q)\) and \(x = k_B T_m\) and designate \(y_0\) as the logarithmic term independent of both \(q\) and \(T_m\), Eq. (27) becomes

\[
y = y_0 + \frac{E}{x} - 2(b-1) \frac{x}{E} + (b-1)^2 \frac{x^2}{E^2} - \frac{8}{3} (b-1)^3 \frac{x^3}{E^3} + \ldots 
\]  
(28)

which can be plotted and fit using a simple fitting program. Mahesh et al. [2] solve this in a very different way:

\[
\ln \left( \frac{T_m^{b-1}}{q} \left( \frac{T_m^2}{q} \right)^b \right) = b\ln E + \ln \left( \frac{(s' n_0^{b-1})^{b-1}}{(s' k_B)^b} \right) + \frac{E}{k_B T_m} 
\]  
(29)

Eq. (29) shows dependence on intensity, which adds a further source of uncertainty. Detector zero drift, overlapping glow curve peaks, nonlinear intensity response by the detector, or other misleading intensity measurements will add error to calculations. Thus, Eq. (27) is preferred over Eq. (29) since it contains less factors that may create further sources of error.

The general order method of two heating rates can be solved by subtracting Eq. (27) for two different measurements

\[
0 = \frac{E}{k_B} \left( \frac{T_{m1}^{b-1}}{q_{m1}} \frac{T_{m2}^2}{q_{m2}^2} \right) + \ln \left( \frac{q_{m2}}{q_{m1}} \right) \frac{T_{m2}^2}{q_{m2}^2} + \frac{2(b-1)k_B}{E} (T_{m2} - T_{m1}) - \frac{2(b-1)^3 k_B^3 T_{m2}^3}{3 E^2} (T_{m2} - T_{m1})^2 + \ldots 
\]  
(30)

This is easiest solved graphically. After inputting all the known values for \(T_{m1}\) and \(q_i\) and the constants and letting \(x = E\), we can write Eq. (30) as

\[
y = Ax + B + C \frac{E}{x} + \frac{D}{x^2} + \frac{E}{x^3} - \ldots 
\]  
(31)

which can be plotted to find the \(x\)-intercept = \(E\). The substitutions made are as follows:
\[ A = \frac{1}{k_B} \left( \frac{1}{T_{m1}} - \frac{1}{T_{m2}} \right), \]
\[ B = \ln\left( \frac{q_1 T_{m2}^2}{q_2 T_{m1}} \right), \]
\[ C = 2(b-1)k_B(T_{m2} - T_{m1}), \]
\[ D = 2(b-1)^2 k_B^2(T_{m2} - T_{m1}), \]
\[ E = \frac{8}{3} (b-1)^3 k_B^3(T_{m2}^3 - T_{m1}^3). \]  

We may check our work here by setting \( b = 1 \) in Eq. (30), and we see that we return the first-order kinetics solution of Eq. (22).

The obvious challenge with this method, however, is the required guesswork for the order \( b \).

The solution presented by Mahesh et al. [2] for the general order method of two heating rates is
\[ \frac{T_{m2}^2}{q_1} \left( \frac{1}{b-1} + \frac{2k_B T_{m1}}{E} \right) \exp \left( -\frac{E}{k_B T_{m1}} \right) = \frac{T_{m2}^2}{q_2} \left( \frac{1}{b-1} + \frac{2k_B T_{m2}}{E} \right) \exp \left( -\frac{E}{k_B T_{m2}} \right) \]  

which is not so easily solved for \( E \) and still requires inputting an assumed \( b \). If \( b = 1 \), this can also be shown to return the first-order kinetics solution of Eq. (22).

Thus, we have formulated the theory for the initial rise method (Eq. 10), which can be applied to general order kinetics, the first-order method of two heating rates (Eq. 22) and variable heating rate method (Eq. 24), and general order method of two heating rates (Eq. 30) and variable heating rate method (Eq. 27).

5. Experimental setup

A schematic of a standard TL dosimetry reader (TLD) is shown in Figure 5. The irradiated dosimeter is mounted on a tray located within a readout chamber. Two different temperatures are used for heating the dosimeter, first one is preheating to clear noisy peaks and second one is readout temperature used to thermally stimulate the sample and collect data. Nitrogen gas is continuously pumped to decrease spurious phenomena [72] and reduce the background.

The absorbed dose is proportional to the output current received from photomultiplier tube [73].

We have developed an advanced TL setup that uses a special heating stage with an optical window that transmits light and blocks heat to achieve perfect temperature control during the measurement. Solarized fiber optics connected to collimation lenses are used to collect the emitted light (Figure 6). The TL spectra are recorded by a CCD detector with a 200 µm slit. The spectral range of the detector can be adjusted from 200 to 800 nm or from 350 to 1100 nm with 1 nm resolution. The optical components are water cooled to allow for high temperature
(up to 400°C) TL measurements. Before TL experiment, we often irradiate the samples in dark for certain time using xenon lamp, light emitting diodes (LEDs), or 254 nm irradiation panel. The spectral range of the xenon lamp is 220–750 nm. This setup has many advantages including:

1. Precise control and measurements of temperature, 1 mK precision and high stability.
2. Adjustable heating/cooling rate, can go up to 1000°C/min. In most measurements, it is operated at 60°C/min and 120°C/min. Using different heating rates is required to calculate trap levels by variable heating rate methods.
3. TL can be measured as a function of temperature and wavelength simultaneously as shown in (Figure 7).
A TL measurement is performed in a dark box in a temperature-insulated heating stage as discussed above and as shown in the figure. This is because the TL emission is relatively weak, so it is necessary to isolate the measurement from ambient lighting that would greatly interfere with it. The heating stage must be also temperature isolated for two reasons. First, it makes it possible to fully control the temperature of the sample instead of potentially creating a gradient of temperature across the thickness of the sample. Second, it separates the optical components used for excitation and measurement so that they may be operated independently.

6. TL applied to dielectrics

Dielectric materials possess a large band gap separating the valence and conduction bands. This large gap determines the characteristic insulating properties. Dopants, defects, and impurities alter the band structure of a dielectric material by adding energy levels and electron and electron hole traps within the band gap. Charge carrier traps can be vacancy, interstitial, substitutional, or antisite defects. Typically, charge carriers can be trapped at defects of the opposite charge. For instance, an anion vacancy is positively charged and would thus trap an electron. However, the behavior of some impurity traps depends on the electronic structure of...
For instance, in YAG, Eu	extsuperscript{3+}, and Yb	extsuperscript{3+} impurities have been found to act as stable electron traps at room temperature due to their large electron affinity. Meanwhile, Pr	extsuperscript{3+}, Tb	extsuperscript{3+}, and Ce	extsuperscript{3+} were found to act as hole traps, stable at room temperature [45, 57]. At low temperatures, other traps stabilize, such as Sm	extsuperscript{3+} electron traps.

TL can be used to characterize defects and provide quantitative information about charge carrier traps. It shares many similarities to color center measurements [76]; however, it has more advantages in evaluating the trap depths in the band gap. In color center measurements, a sample is irradiated for a period of time with an excitation source, similar to the first step for a TL measurement. Absorption spectra of this sample are recorded before and after excitation. As discussed previously, this excitation leads to the trapping of some charge carriers at defects. These trapped charge carriers carry their own optical properties, which are observable in absorption measurements. On top of that, an irradiated sample may be visibly discolored. Heating to sufficiently high temperature bleaches this discoloring and returns the trapped charge carriers to recombination centers. TL is the qualitative study of this effect. Figure 8 shows the absorption spectra of undoped YAG before and after irradiation and after heating to 400°C. This sample will be also used later for TL glow curves presented in Figure 12. Some qualitative information can be gained from this figure in conjunction with prior knowledge about the sample, such as ascribing the peak at 256 nm to Fe impurities [77, 78]. These plots give no information about the depth of these traps other than the fact that heating to 400°C seemed to clear them up which implies that they are deep centers. TL provides the more qualitative analysis.

We will discuss our TL study on Ce:YAG as an example of dielectric materials because of its great importance in a wide range of applications from phosphors to scintillation. In general, YAG is one of the most important optical materials, with Nd:YAG as the most widely used laser crystal. As it stands now, Ce:YAG is an efficient luminescent material, but its performance as a scintillator is often hindered by the presence of traps.

6.1. YAG TL

In our TL measurements on YAG crystals [55], samples were cooled or heated within a temperature range of −190 to 400°C and TL spectra are recorded as described in the experimental section. Glow curves were constructed by integrating each spectrum over a specific range of wavelengths. In Ce-doped YAG, Ce ions provide the recombination centers and thus all TL emission are shown to have the luminescence profile characteristic of Ce ions in YAG, as shown in Figure 9. For the sake of demonstration, a contour plot of temperature versus wavelength for the same sample is provided in Figure 10, demonstrating only one luminescence center.

Sometimes care had to be taken when integrating over wavelengths to distinguish between different luminescence centers activating at different temperatures. Figure 11 shows the contour plot of temperature versus wavelength for an undoped YAG sample, originally grown in a pure Ar atmosphere, where the luminescence centers are comprised of different trace impurities. Something else to note in Figure 10 is the onset of IR emission near 400°C due to blackbody radiation. The wavelength of this IR emission overlapped slightly with the integration range of one of the peaks and was visible in the constructed glow curve. Also note the
much weaker emission, as each contour now corresponds to a step of 200 counts, whereas in Figure 10, it corresponded to 1500 counts. The IR radiation was too weak to show on the contour plot of Figure 10. The Ar-grown undoped YAG sample was annealed at 1200° for 96 hours in air. Figure 12 presents the two unique glow curves for this sample before and after annealing, separately integrating over the wavelength ranges 340–570 and 570–800 nm. The intensity of most peaks has been decreased suggesting decreased concentration of their corresponding defects. Also, the high-temperature peak in the high-wavelength plot shifts significantly, suggesting a change in activation energy. Activation energies were calculated for each of these peaks and frequency factors were calculated whenever possible for the as-grown sample. The small peak in the high-wavelength glow curve at 180°C had too high of uncertainty to get a reliable estimate for s. Results are tabulated in Tables 2 and 3.

Obviously, the activation energy increases with temperature, as charge carriers at deeper traps require more thermal energy for release. The most noticeable change is the large decrease in
activation energy of the highest energy peak after annealing by about 0.9 eV. Due to the nature of anneal, it seems reasonable to attribute this defect partially to oxygen vacancies. However, the fact that the peak persists, just at a decreased activation energy, suggests that there still exists a defect, suggesting that the original defect was a complex defect consisting of both at least one Al vacancy and at least one O vacancy, and the anneal filled one O vacancy but left the Al vacancy. The depth of the low-wavelength peak at 250°C appears to decrease slightly after annealing, possibly due to the change in charge state of the impurity responsible for this luminescence and/or change of lattice defect structures surrounding them. No other activation energy appeared to change after annealing, so it would appear that annealing only decreased their concentration and not their depth.

Positron annihilation lifetime spectroscopy (PALS) measurements were also performed on these samples in combination with TL [79]. PALS works by injecting a positron into the crystal and timing how long it takes to annihilate with an electron within the sample. If the positron annihilates within the bulk of the sample, the process is very fast (of order 0.1 ns). If the positron becomes trapped at a vacancy or void, it takes longer to annihilate with an electron.

Figure 9. TL emission spectrum at 262°C for Ce:YAG 0.14%.
due to the reduced number density of electrons at vacancies. Due to their positive charge, positrons typically trap at negatively charged vacancies or voids, such as cation vacancies, or neutral voids, such as cation + anion vacancy complexes. Typically, a larger vacancy means a lower number density of electrons and thus longer positron lifetime [80, 81].

PALS measurements on these YAG samples demonstrated a defect lifetime (i.e., the lifetime of a positron trapped at a defect) of $0.2931 \pm 0.0032$ ns for the as-grown sample and $0.2691 \pm 0.0037$ ns for the annealed sample, suggesting that annealing in air decreased the size of the defect but did not entirely eliminate it. This defect bears striking similarity to the peak in Figure 12 that moved from 395 to 345°C after annealing in air and in fact the same conclusion may be drawn from this PALS result that this defect is due to an Al + O vacancy complex.

PALS measurements only identified one defect that trapped the injected positrons, suggesting that the remaining defects arose from either positively charged vacancies or nonvacancy complexes.
Figure 11. Contour plot of TL of undoped YAG grown in a pure Ar atmosphere, plotting luminescence intensity contours to a map of temperature versus wavelength. Each contour represents a step of 200 counts [79].

Figure 12. Glow curves for Ar-grown undoped YAG before and after annealing. The low wavelength curve (left) was integrated over 340–570 nm, the high wavelength curve (right) was integrated over 570–800 nm.
defects, such as impurities. Since a positively charged vacancy in this crystal means an O vacancy, annealing in air would be expected to eliminate or decrease this defect, and consequently any TL peaks associated with it. Other TL peaks that are not sensitive to air anneal can be ascribed to impurities.

6.2. Low-temperature TL of Ce:YAG

Low-temperature glow curves for Ce:YAG 0.14%, presented in Figure 13, provide an abundance of information. The sample was measured, then annealed in air for 48 hours at 1200°C and remeasured, then annealed in a vacuum for 24 hours at 800°C and measured once again. TL emission spectra were integrated over the wavelength range of 470–720 nm, which encompasses the strong and well-documented Ce luminescence peak in YAG peaked around 550 nm [51, 56, 57, 78, 82–106]. From figure, it can be seen that the highest intensity peak at −75°C is completely eradicated by annealing in air, but it returns after annealing in vacuum. With this information, it is easy to identify this trap as an oxygen vacancy. Upon eliminating this peak, TL emission can be distinguished near −100°C in the air-annealed sample. Curve fitting resolves that it is as two peaks centered at about −100 and −90°C. A weak peak at about −10°C appears to be eliminated by annealing in air.

Activation energies were calculated to compare the as-grown and air-annealed samples and are provided in Table 4. Interestingly, although all traps appear to decrease drastically in concentration, their depths uniformly increase.

These examples demonstrate some of the analytical capabilities of TL spectroscopy. The high-concentration oxygen vacancies observed in Figure 13 at −75°C are not stable at room

<table>
<thead>
<tr>
<th>Approximate peak location (q = 60°C/min)</th>
<th>Activation energy</th>
<th>Frequency factor</th>
</tr>
</thead>
<tbody>
<tr>
<td>250°C</td>
<td>1.47 ± 0.23 eV</td>
<td>0.95 ± 0.09 eV</td>
</tr>
</tbody>
</table>

Table 2. Calculated activation energies of Ar-grown undoped YAG for the glow curves constructed using 340–570 nm integration.

<table>
<thead>
<tr>
<th>Approximate peak location (q = 60°C/min)</th>
<th>Activation energy</th>
<th>Frequency factor</th>
</tr>
</thead>
<tbody>
<tr>
<td>110°C</td>
<td>1.65 ± 0.01 eV</td>
<td>1.63 ± 0.09 eV</td>
</tr>
<tr>
<td>180°C</td>
<td>3.04 ± 2.27 eV</td>
<td>1.44 ± 1.87 eV</td>
</tr>
<tr>
<td>250°C</td>
<td>1.92 ± 0.09 eV</td>
<td>2.07 ± 0.15 eV</td>
</tr>
<tr>
<td>345°C</td>
<td>N/A</td>
<td>2.23 ± 0.55 eV</td>
</tr>
<tr>
<td>395°C</td>
<td>3.15 ± 0.25 eV</td>
<td>N/A</td>
</tr>
</tbody>
</table>

Table 3. Calculated activation energies of Ar-grown YAG for the glow curves constructed using 570–800 nm integration.
Figure 13. Low-temperature glow curves of Ce:YAG 0.14% as grown, annealed in air, and annealed in a vacuum using 470–720 nm integration.

<table>
<thead>
<tr>
<th>Approximate peak location (q = 60°C/min)</th>
<th>As grown</th>
<th>Annealed in air</th>
</tr>
</thead>
<tbody>
<tr>
<td>−170°C</td>
<td>0.20 ± 0.01 eV</td>
<td>0.37 ± 0.03 eV</td>
</tr>
<tr>
<td>−140°C</td>
<td>0.27 ± 0.01 eV</td>
<td>0.39 ± 0.02 eV</td>
</tr>
<tr>
<td>−100°C</td>
<td>N/A</td>
<td>0.38 ± 0.15 eV</td>
</tr>
<tr>
<td>−90°C</td>
<td>N/A</td>
<td>0.67 ± 0.06 eV</td>
</tr>
<tr>
<td>−75°C</td>
<td>0.55 ± 0.01 eV</td>
<td>N/A</td>
</tr>
<tr>
<td>−45°C</td>
<td>0.66 ± 0.01 eV</td>
<td>0.81 ± 0.01 eV</td>
</tr>
<tr>
<td>−10°C</td>
<td>0.90 ± 1.04 eV</td>
<td>N/A</td>
</tr>
</tbody>
</table>

Table 4. Calculated activation energies of Ce:YAG 0.14% for the glow curves constructed using 470–720 nm integration range.
temperature but would play a major role in any low-temperature processes involving Ce:YAG crystal. It also affects exciton dynamics in YAG crystal. It is clear how different processing affects the defect structure and concentration within these samples.

7. TL applied to semiconductors

7.1. Calculations of donor ionization energies in ZnO

In this section, we discuss a new application of TL that implies the use of low-temperature TL for the measurements of donor ionization energy in luminescent semiconductors. TL spectroscopy has been already applied in combination with other methods to identify defects in a few semiconductors as mentioned earlier in the chapter. However, the focus here is on its development as a method for donor ionization energy calculations. We have recently shown that it is possible to apply low-temperature TL to measure donor ionization energies in luminescent semiconductor. The study has been carried out on ZnO, one of the most important wide band gap semiconductors with many existing and future applications [107]. It is also considered one of the most

![Figure 14. Contour plot of TL emission as a function of temperature and wavelength for as grown and annealed ZnO single crystals. 60°C/min was used for heating rate [116].](image-url)
complex binary system in terms of defects and optoelectronic properties. There are several established methods for calculating donor and acceptor ionization energies in semiconductors. Temperature-dependent Hall-effect is the most common method, it is crucial for semiconductor characterization [108–110], however it suffers limitations in specific cases, and TL may provide an alternative method in these cases as explained below. Electron paramagnetic resonance (EPR) [110], and photoluminescence [111–115] have also been applied to measurements of donor ionization energies, however, EPR is very limited and PL alone may be not capable of measuring the donor ionization energy due to the collapse of exciton.

Low-temperature TL has been recently applied on as-grown and annealed ZnO single crystals [116]. Annealing was carried out in different atmospheres: (1) hydrogen atmosphere at 300°C for 1 hour. (2) Oxygen atmosphere at 1100°C for 1 hour. (3) Both atmospheres in different order. Figure 14 represents the contour plots for as-grown and annealed samples, two peaks can be seen at 520 and 580 nm, which are slightly changed with the annealing atmospheres. Figure 15 shows the glow curves for as-grown and annealed samples. Three donors were identified in the samples from the glow curves and their ionization energies were found to be 47 ± 3, 55 ± 5, and 36 ± 2 meV. The first two energies are in agreement with Lavrov [111, 112].

Figure 15. TL glow curve of ZnO single crystals produced from contour plots shown in Figure 14 (a-c) [116].
reports, the 47 meV was attributed to hydrogen bound in oxygen vacancy (H\textsubscript{O}), and the 55 meV was related to hydrogen at a bound centered lattice site (H\textsubscript{BC}). The 36 meV has also been reported for ZnO, and its origin is still in debate. Figure 16 reveals the spectral range of TL emission that shows two peaks at 580 and 520 nm green luminescence centers, the ratio between them is dependent on the annealing conditions. The 580 nm emission peak is attributed to the Zn-O vacancy pairs which have been modified after annealing in O\textsubscript{2} (Figure 16b). The 520 nm peak was reported as O-vacancy related defects, this peak was declined for the sample annealed in H\textsubscript{2} first and then annealed in O\textsubscript{2} where the 36 meV ionization energy has been measured. The reason behind it is that oxygen fills oxygen vacancies rather than Zn-O vacancies due to the formation of stable H-Zn vacancy complex defects, which supports the association of the 36 meV with “three or more hydrogen in Zn vacancy” donor. These TL measurements revealed the three known donors for ZnO in a single experiment, while each other method was only capable of measuring one type of the three donors. It should be noted that TL could be especially useful for small nonuniform samples because Hall-effect measurements require uniform sample and its resolution is limited to 5 x 5 mm.

Figure 16. Emission peaks for as grown and annealed ZnO single crystals. Annealing atmosphere shows strong effects on the ratio of 580 and 520 nm [116].
Moreover, characterizing donors and acceptors in thin films on conductive layers using Hall-effect is a real challenge as the current diffuses to the conductive substrate and the measurements give a false indication for the electrical transport properties of the film. We expect that TL could be an alternative method for donor characterization in thin films on conductive layers.

8. Conclusion

The chapter reviewed the basics of TL spectroscopy and its applications and described an advanced TL setup to extend its applications to the study and measurements of trap levels in semiconductors and dielectrics. Different methods for the analysis of TL glow curve and the calculations of activation energies were presented. By applying TL spectroscopy to the study of YAG and ZnO, we demonstrated the effectiveness of the technique in characterizing trap levels and measuring donor ionization energies in dielectrics and semiconductors, which is crucial to understand their electronic properties. By combining TL with other spectroscopies such as positron annihilation, Fourier transform infrared, and optical absorption spectroscopies, full characterization of trap levels in the band gap can be obtained. This is especially important for wide band gap materials where defects and dopants in the band gap determine most of the optical, electrical, and magnetic properties.

Author details

Pooneh Saadatkia, Chris Varney and Farida Selim

*Address all correspondence to: faselim@bgsu.edu

1 Center for Photochemical Sciences, Bowling Green State University, Bowling Green, OH, USA

2 Seattle University, Seattle, WA, USA

References


[22] Shinsho K, Suzuki Y, Yamamoto Y, Urushiyama A. The thermoluminescence activation energy and frequency factor of the main glow of CaSO 4: Tm phosphor determined by


http://dx.doi.org/10.5772/65306

Trap Level Measurements in Wide Band Gap Materials by Thermoluminescence

http://dx.doi.org/10.5772/65306


